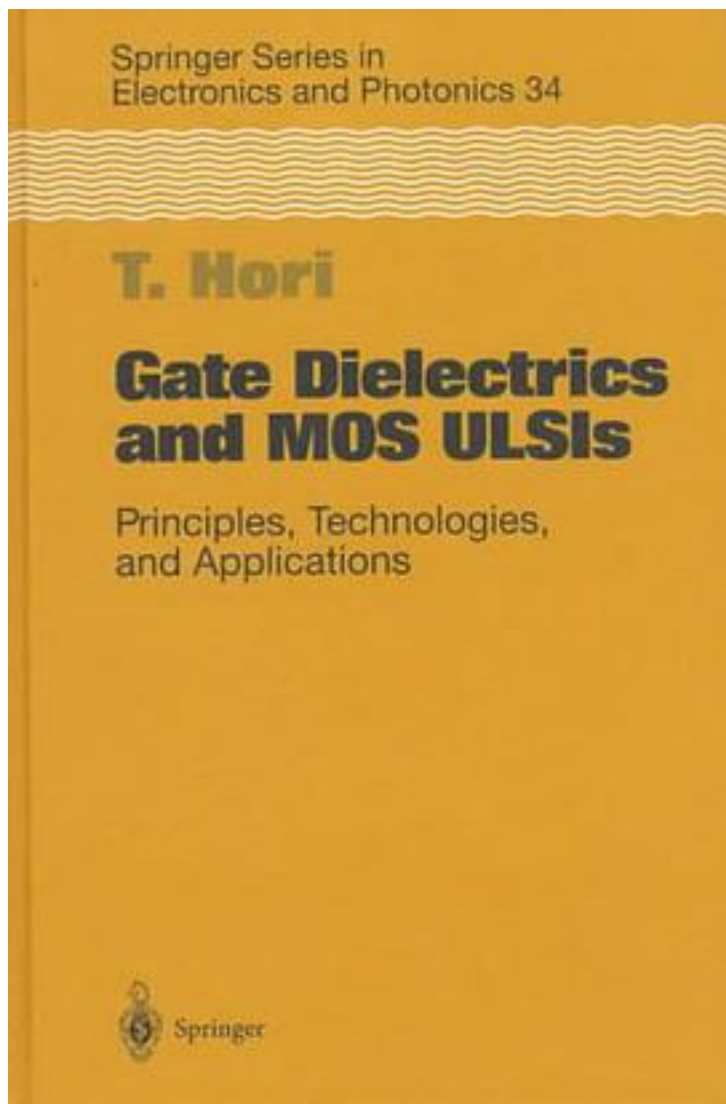


Gate Dielectrics and Mos Ulsis



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Gate Dielectrics focusses on dielectric films satisfying the superior quality gate dielectric even in large-scale integration. The information presented is rather up to date with regard to nanometer-range ultrathin gate-dielectric films, which are indispensable for submicrometer ULSIs.

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目录:

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